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(12) **United States Design Patent**
Chen

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(54) **MASK**

(71) Applicant: **Chun-Nan Chen**, Tainan (TW)

(72) Inventor: **Chun-Nan Chen**, Tainan (TW)

(**) Term: **15 Years**

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(52) **U.S. Cl.**
USPC **D29/108**

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D2/878, 880, 881; D24/110.1; 2/455,
2/456, 410, 423, 424, 425.9, 171, 173,
2/206, 207, 906; 128/857, 858, 201.23,
128/201.24, 206.21
CPC .. A42B 3/18; A42B 3/185; A42B 3/20; A42B
3/32; A42B 3/322; A42B 3/00; A63B
71/10; A63B 2071/105; A61F 9/04; A61F
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See application file for complete search history.

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Primary Examiner — Elizabeth J Oswecki

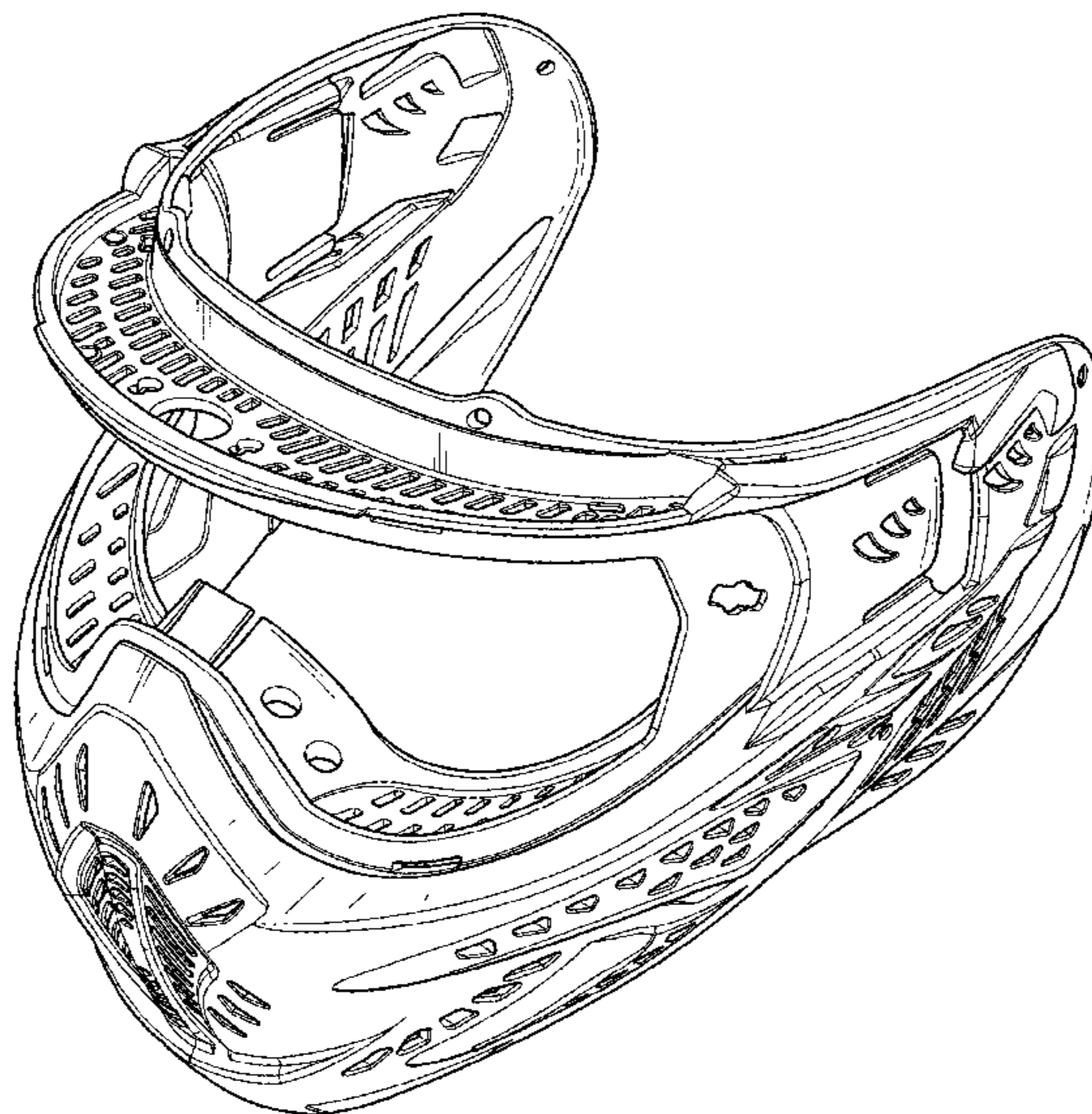
(57) **CLAIM**

The ornamental design for a mask, as shown and described.

DESCRIPTION

Fig. 1 is a perspective view of a mask showing my design;
FIG. 2 is a front elevational view thereof;
FIG. 3 is a rear elevational view thereof;
FIG. 4 is a left side elevational view thereof;
FIG. 5 is a right side elevational view thereof;
FIG. 6 is a top plan view thereof; and,
FIG. 7 is a bottom plan view thereof.

1 Claim, 7 Drawing Sheets



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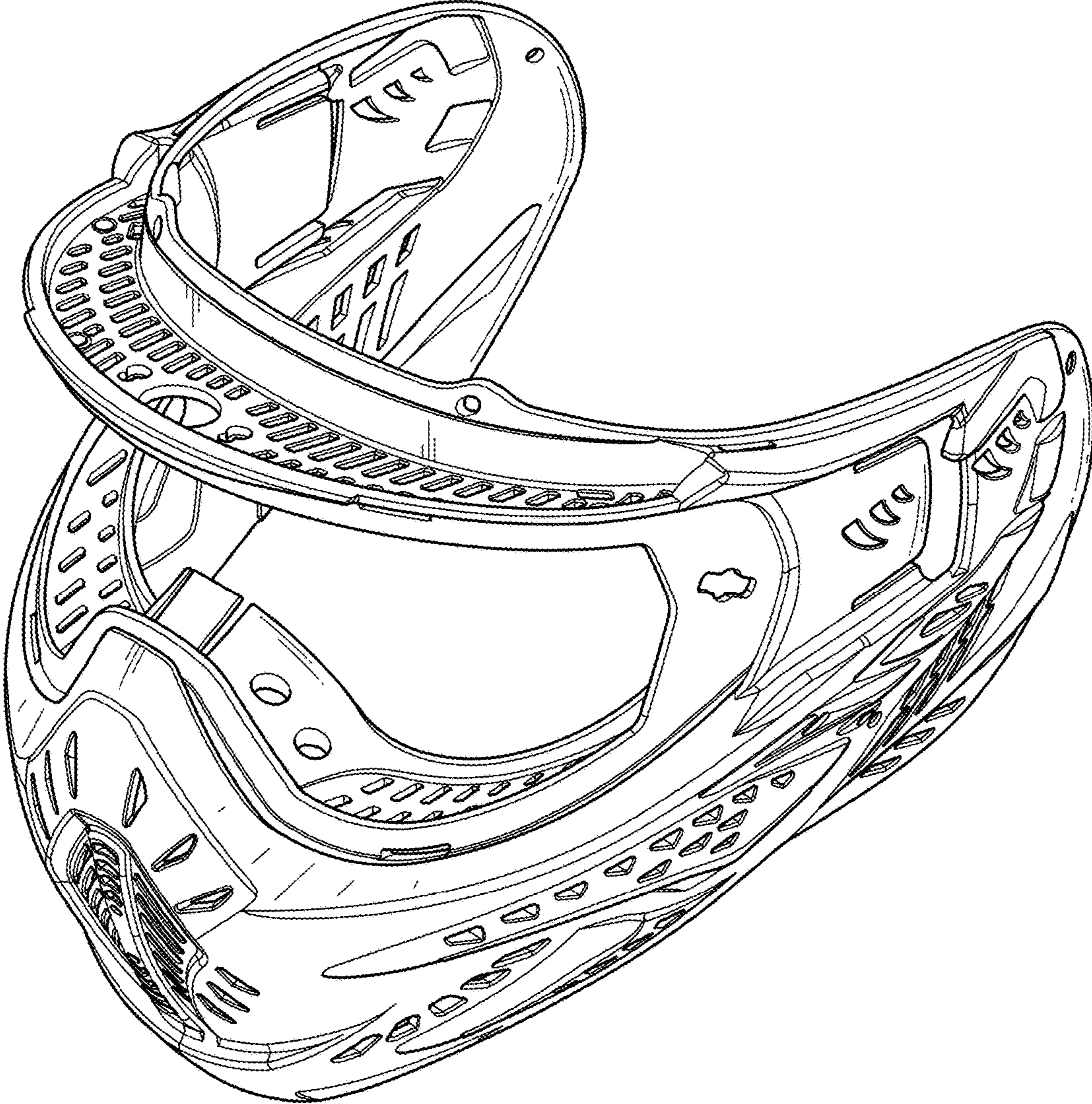


FIG. 1



FIG. 2



FIG. 3

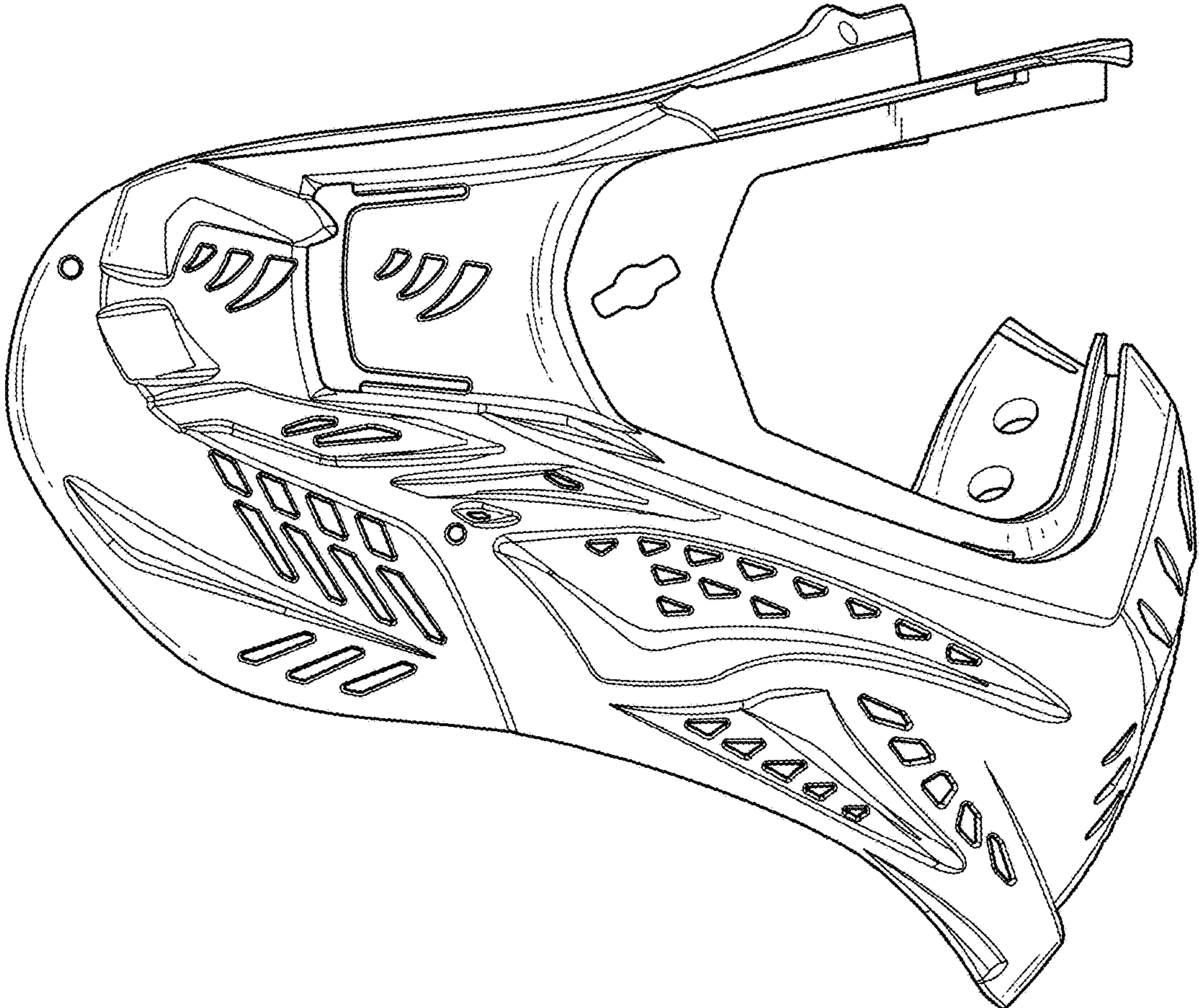


FIG. 4

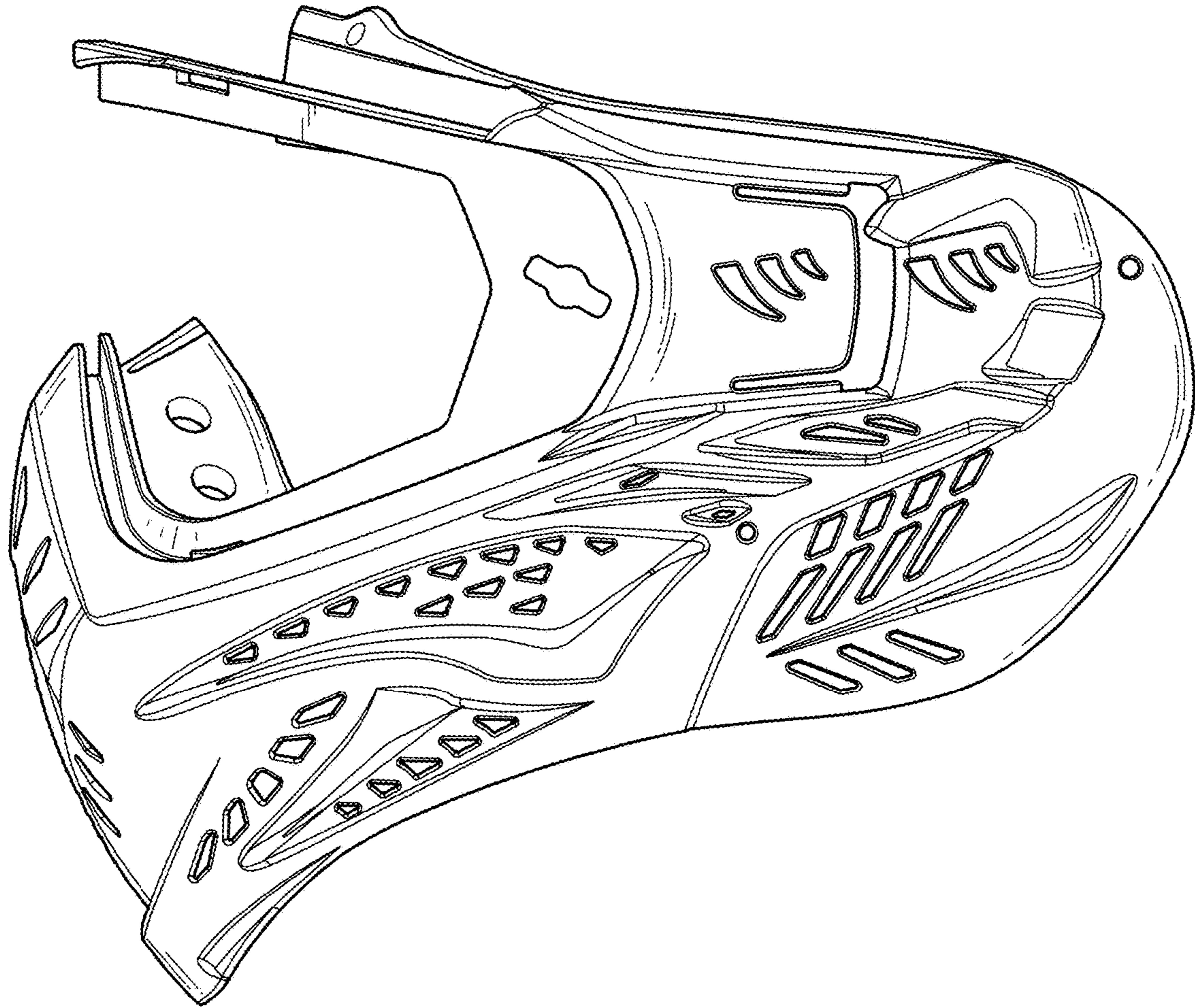


FIG. 5



FIG. 6



FIG. 7